A(4-F1A, 12-L3D) E(5-L2C) G(6-A3, 6-A11, 6-F4, 6-F5) L(3-G5) R1-R4= H or methoxy independently.	Also claimed, are: (1) an optical filter(II) for plasma display comprising (I) and one of electrically conductive layer, antistatic layer or reflection insulating layer; and (2) an optical filter(III) for plasma display comprising (I) or (II) and glass plate or plastic plate(s) to support (I) or (II).	ADVANTAGE (I) absorbs near infrared ray selectively. Using (I), (II) or (III), clear image of plasma display is obtained, errors of electrical and electronic instruments can be avoided by using (I), (II) or (III).	EMBODIMENT (A) is film(s) or sheet(s) of methyl methacrylate homopolymer plate or methyl methacrylate copolymer. Polymer(s) corresponding to (A) and (B) are blended to become (B) content in (I) to 0.07-1.07
99-148685/13 A89 E23 G06 L03 **JP 11012425-A MITSUBISHI RAYON CO LTD **JP 11012425-A 97.06.23 97JP-165923 (99.01.19) C08L 33/00, C08K 5/36, C09K 3/00, G02B 5/22, H01J 11/02, F21V 9/04, C08K 5/56 // C08J 5/00 Optical filter for plasma display.	Optical filter(I) for plasma display comprising (A) and (B) is claimed. (A): acrylic resin film(s) or sheet(s) (B): nickel complex(es) of formula (I):		

insulating layer(e.g. silica layer, titania layer etc) is formed on (I) surface to obtain (II). (I) or (II) is formed on glass or plastic plate(s) 0.39 g/m² to obtain (I). (I) showed transmittance 15 % at 920 nm, 68 Acrypet VH(RTM), the mixt. was moulded to film containing (B1) g/m^2 , the mixt. moulded to film(s) or sheet(s) to obtain (I). One of ayer), antistatic layer(e.g. surface active agent layer) or reflection electrically conductive layer(e.g. silver thin layer and/or ITO thin (B1), cpd. R1-R4= p-methoxy in formula (1), was added to % at 450-680 nm region. (4pp129DwgNo.0/0) **EMBODIMENT** to obtain (III).